

IPW

**PATENT APPLICATION**

THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Yasutsugu SOETA

Group Art Unit: 3723

Application No.: 10/573,497

Docket No.: 127462

Filed: March 27, 2006

For: POLISHING PAD, METHOD FOR PROCESSING POLISHING PAD, AND  
METHOD FOR PRODUCING SUBSTRATE USING IT

**REQUEST FOR CORRECTION OF PALM RECORDS**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the updated filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

William P. Berridge  
Registration No. 30,024

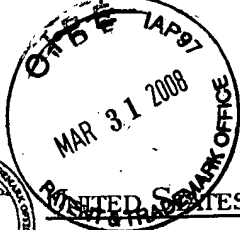
Mario A. Costantino  
Registration No. 33,565

WPB:MAC/bab

Date: March 31, 2008

**OLIFF & BERRIDGE, PLC**  
**P.O. Box 320850**  
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<p><b>DEPOSIT ACCOUNT USE AUTHORIZATION</b> Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461</p>
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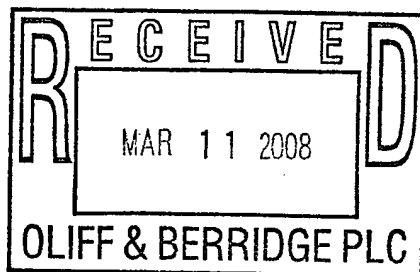
UNITED STATES DEPARTMENT OF COMMERCE  
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APPLICATION NUMBER	FILING or 371(c) DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	TOT CLAIMS	IND CLAIMS
12/003,839	01/02/2008	3723	1030	127462.01	12	2

CONFIRMATION NO. 5980

UPDATED FILING RECEIPT

25944  
OLIFF & BERRIDGE, PLC  
P.O. BOX 320850  
ALEXANDRIA, VA 22320-4850



Date Mailed: 03/10/2008

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections**

**Applicant(s)**

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**Assignment For Published Patent Application**

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**Domestic Priority data as claimed by applicant**

This application is a DIV of 10/573,497 03/27/2006  
which is a 371 of PCT/JP2004/013661 09/17/2004

**Foreign Applications**

JAPAN 2003-335939 09/26/2003

Request to Retrieve - This application either claims priority to one or more applications filed in an intellectual property Office that participates in the Priority Document Exchange (PDX) program or contains a proper **Request to Retrieve Electronic Priority Application(s)** (PTO/SB/38 or its equivalent). Consequently, the USPTO will attempt to electronically retrieve these priority documents.

**If Required, Foreign Filing License Granted: 02/05/2008**

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US 12/003,839**

**Projected Publication Date:** 06/12/2008

**Non-Publication Request:** No

**Early Publication Request:** No  
**Title**

Polishing pad, method for processing polishing pad, and method for producing substrate using it

**Preliminary Class**

451

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